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FOREIGN PATENT DOCUMENTS						
Examiner Initial	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
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	NON PATENT LITERATURE
Examiner Initial	Include name of author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.
VV AA	Zhang et al., "An Integrated Approach for Database Security and Fault Tolerance", Proceedings of the International Conference on Information Technology: Coding and Computing, 2004, pp. 762-766.
AB	Zhang et al., "An Efficient Authentication Scheme with Fault Tolerance for Database Systems", Proceedings of the Third International Conference on Information Technology and Applications, 2005, pp. 448-453.
M AC	Mohan, "Privacy and Authentication Protocols for PCS", IEEE Personal Communications, Vol. 3, Issue 5, October 1996, pp. 34-38.

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